



The 3rd CSIS International Symposium on Spintronics-based VLSIs

and

The 11th RIEC International Workshop on Spintronics

Date: January 31 and February 1, 2013

Venue: Laboratory for Nanoelectronics and Spintronics,
4th Floor, Conference Room, Tohoku University,
Sendai, Japan

<http://www.csis.tohoku.ac.jp/>

Symposium Registration

Registration: E-mail to CSIS Support Office (sien@csis.tohoku.ac.jp) by January 25th, 2013.

Symposium Fee: Free

Banquet Registration

Advance Registration: E-mail to CSIS Support Office (sien@csis.tohoku.ac.jp) by January 15th, 2013.

Banquet Fee: 5,000 JPY
Banquet Fee will be collected on site at the Symposium

Sponsors

The symposium and the workshop are sponsored and supported by:

- Cabinet Office, Government of Japan
- Ministry of Education, Culture, Sports, Science & Technology, Japan
- Japan Society for the Promotion of Science (JSPS) through the “Funding Program for World-Leading Innovative R&D on Science and Technology (the FIRST Program)”
- Research Institute of Electrical Communication (RIEC), Tohoku University
in cooperation with Nation-wide Cooperative Research Projects

Organizers

Hideo Ohno (CSIS and RIEC, Tohoku University)

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Tohoku University)

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PROGRAM

Thursday January 31, 2013		
- Materials and Devices -		
Opening 9:00 -9:10		Opening remarks <u>Hideo Ohno</u> (Tohoku University)
Invited talk 9:10-9:45	T1	Spin Torque MRAM using Perpendicular Magnetic Anisotropy <u>Daniel C. Worledge</u> ¹ , D. W. Abraham ¹ , S. Brown ¹ , M. Gajek ¹ , M. C. Gaidis ¹ , G. Hu ¹ , K. Kita ^{1,2} , J. Nowak ¹ , E. J. O'Sullivan ¹ , R. P. Robertazzi ¹ , J. Z. Sun ¹ , P. L. Trouilloud ¹ , and W. J. Gallagher ¹ (¹ IBM, ² The University of Tokyo)
Invited talk 9:45-10:20	T2	Write Error Rate in STT-MRAM Zihui Wang, Yuchen Zhou, Jing Zhang, Kimi Satoh, Jung Dong Ha and Yiming Huai (Avalanche Technology)
10:20-10:40		Coffee Break
Invited talk 10:40-11:15	T3	Challenges of STT-MRAM for High Density Memory <u>Gwan-Hyeob Koh</u> (Samsung Electronics)
Invited talk 11:15-11:40	T4	Magnetic tunnel junctions using $L1_0$ ordered MnAl electrode <u>Mikihiko Oogane</u> , H. Saruyama, Y. Kurimoto, H. Naganuma and Y. Ando (Tohoku University)
Invited talk 11:40-12:05	T5	Junction size dependence of intrinsic critical current and thermal stability of MgO/CoFeB/Ta/CoFeB/MgO recording structure <u>Hideo Sato</u> , M. Yamanouchi, S. Ikeda, S. Fukami, F. Matsukura, and H. Ohno (Tohoku University)
12:05-14:00		Lunch
Invited talk 14:00-14:35	T6	Comparison between static and dynamic measurements of the spin Hall effect <u>Yoshichika Otani</u> ^{1,2} , K. Kondou ² , Y. Niimi ¹ , S. Kasai ³ , H. Sukegawa ³ , and S. Mitani ³ (¹ The University of Tokyo, ² Riken-ASI, ³ NIMS)
Invited talk 14:35-15:10	T7	Spin transfer torques in magnetic bilayers with strong spin orbit coupling P. M. Haney ¹ , H.-W. Lee ² , K.-Jin Lee ^{3, 4, 1, 5} , A. Manchon ⁶ , and <u>Mark D. Stiles</u> ¹ (¹ National Institute of Standards and Technology, ² Pohang University of Science and Technology, ³ Korea University, ⁴ Korea Institute of Science and Technology, ⁵ University of Maryland, ⁶ King Abdullah University of Science and Technology)
Invited talk 15:10-15:35	T8	Current induced torques in magnetic heterostructures <u>Masamitsu Hayashi</u> ¹ , J. Kim ¹ , M. Yamanouchi ² , S. Fukami ² , T. Suzuki ³ , J. Sinha ¹ , S. Mitani ¹ , and H. Ohno ² (¹ National Institute for Materials Science, ² Tohoku University, ³ Renesas Electronics Corporation)

15:35-15:55	Coffee Break	
Invited talk 15:55-16:20	T9	Three terminal switching devices based on an interconnection material Cu <u>Michihiko Yamanouchi</u> , L. Chen, H. Sato, S. Fukami, S. Ikeda, F. Matsukura, and H. Ohno (Tohoku University)
Invited talk 16:20-16:45	T10	Electric Field-induced Magnetization Switching in CoFeB <u>Fumihiro Matsukura</u> ¹ , S. Kanai ¹ , M. Yamanouchi ¹ , S. Ikeda ¹ , Y. Nakatani ² , and H. Ohno ¹ (¹ Tohoku University, ² University of Electro-communications)
Invited talk 16:45-17:20	T11	First Principles Study on the Gilbert Damping Constants of Transition Metal Alloys <u>Akimasa Sakuma</u> (Tohoku University)
17:20-17:30	Coffee Break	
17:30-19:00	POSTER SESSION See pages 5 and 6	
Banquet 19:30-21:00	CACCINU (Italian restaurant), Sendai Kokusai Hotel*, B1 * http://www.tobu-skh.co.jp/english/index.html	

<p style="text-align: center;">Friday February 1, 2013</p> <p style="text-align: center;">Spintronics-based LSIs</p>		
Invited talk 9:00-9:35	F1	Recent Progress in ST-MRAM at Everspin Technologies <u>Jon M. Slaughter, T. Andre, S. Alam, N.D. Rizzo, J. Janesky, R. Whig, F.B. Mancoff, D. Houssameddine, M. L. Schneider, H. -J. Chia, J. J. Sun, S. Aggarwal, K. Nagel, S. Deshpande, B.N. Engel, M. DeHerrera and P. LoPresti (Everspin Technologies)</u>
Invited talk 9:35-10:10	F2	STT-MRAM for Mobile SOC: Embedding Nonvolatile RAM in Application Processors <u>Seung H. Kang (Qualcomm Technologies)</u>
Invited talk 10:10-10:45	F3	High Speed STT-MRAM for Cash Memory and Low Power Nonvolatile Logic with MTJ technology <u>Tetsuo Endoh (Tohoku University)</u>
10:45-11:05		Coffee Break
Invited talk 11:05-11:30	F4	Standby-Power-Free Fully Parallel TCAM Chip Based on Compact Nonvolatile Logic-in-Memory Cell Structure <u>Shoun Matsunaga¹, S. Miura², H. Honjo², K. Kinoshita¹, S. Ikeda¹, T. Endoh¹, H. Ohno¹, and T. Hanyu¹(¹Tohoku University, ²NEC Corporation)</u>
Invited talk 11:30-11:55	F5	Spintronics Primitive Gate with High Error Correction Function <u>Yukihide Tsuji¹, R. Nebashi¹, N. Sakimura¹, A. Morioka¹, H. Honjo¹, K. Tokutome¹, S. Miura¹, T. Suzuki², S. Fukami³, K. Kinoshita³, T. Hanyu³, T. Endoh³, N. Kasai³, H. Ohno³, and T. Sugibayashi¹</u> (¹ NEC Corporation, ² Renesas Electronics Corporation, ³ Tohoku University)
Invited talk 11:55-12:30	F6	MRAM-based Look Up Table for radiation hardened FPGA <u>O.Gonçalves, Guillaume Prenat and B.Dieny (Spintec)</u>
12:30-14:30		Lunch
Invited talk 14:30-15:05	F7	Prospects and Challenges of Magnetic Domain-Wall Racetrack Memory for High-Density Storage <u>Weisheng S. Zhao^{1,2}, N. Ben Romdhane^{1,2}, Y. Zhang^{1,2}, J-O Klein^{1,2}, C. Chappert^{1,2}, R. Mantovan³, A. Lamperti³, R.P. Cowburn⁴, T. Trypiniotis⁴, M. Klau⁵, J. Heinen⁵, B. Ocker⁶, D. Ravelosona^{1,2}</u> (¹ University of Paris Sud, ² CNRS, ³ Laboratorio MDM IMM CNR, ⁴ Univ Cambridge, ⁵ Johannes Gutenberg Univ Mainz, ⁶ Singulus Technologies)
Invited talk 15:05-15:40	F8	Brain Like Computing Based on the Physics of Nano Devices and Materials <u>Tadashi Shibata (The University of Tokyo)</u>
Invited talk 15:40-16:15	F9	Towards a New Paradigm LSI Based on Nonvolatile Logic-in-Memory Architecture <u>Takahiro Hanyu (Tohoku University)</u>
Closing 16:15-16:20		Closing remarks

Thursday January 31, 2013

POSTER SESSION 17:30-19:00

P01	Temperature Dependence of Spin Polarization in Co/Ni Nanowires with Different Co and Ni Thicknesses Determined by Domain Wall Dynamics <u>K. Ueda</u> ¹ , R. Hiramatsu ¹ , D. Chiba ^{1, 2} , S. Fukami ³ , M. Yamanouchi ³ , H. Ohno ³ , Y. Nakatani ⁴ and T. Ono ¹ (¹ Kyoto University, ² Japan Science and Technology Agency, ³ Tohoku University, ⁴ University of Electro-Communications)
P02	High-speed Simulator Including Accurate MTJ Models for Spintronics Integrated Circuit Design <u>N. Sakimura</u> ¹ , H. Koike ² , R. Nebashi ¹ , Y. Tsuji ¹ , A. Morioka ¹ , H. Honjo ¹ , S. Fukami ² , T. Ohsawa ² , T. Hanyu ² , H. Ohno ² , T. Sugabayashi ¹ and T. Endoh ² (¹ NEC Corporation, ² Tohoku University)
P03	Spin Seebeck Thermoelectric Generators <u>A . B . Cahaya</u> ¹ , G.E.W Bauer ² and O.A Tretiakov ¹ (¹ Tohoku University, ² Delft University of Technology)
P04	Effects of Sputtering Deposition Process on Perpendicular Magnetic Anisotropy of [Co/Pt] Multilayers <u>C. Yoshida</u> , Y. Yamazaki, Y. Iba, T. Takenaga and T. Sugii (Low-power Electronics Association & Project)
P05	Spin torque transistor revisited <u>T. Chiba</u> ¹ , G.E. W. Bauer ^{1,2} , Saburo Takahashi ¹ (¹ Tohoku University, ² Delft University of Technology)
P06	Nonvolatile Look-up Table Circuit Using Three-Terminal MTJ-Based Logic-in-Memory Structure <u>D. Suzuki</u> and <u>T. Hanyu</u> (Tohoku University)
P07	The effects of deposition rate and annealing on CoFeB/MgO/CoFeB perpendicular magnetic tunnel junctions Lin-Xiu Ye, Ching-Ming Lee, Hau-Kang Chen, <u>Te-ho Wu</u> (National Yunlin University of Science and Technology)
P08	The role of B and Co in the perpendicular magnetic anisotropy of CoFeB/MgO interface: a first principles study <u>M. Tsujikawa</u> , Y. Miura and M. Shirai (Tohoku University)
P09	Design of Low-Energy Nonvolatile TCAM Using Logic-in-Memory Architecture <u>S. Matsunaga</u> ¹ , and <u>T. Hanyu</u> (Tohoku University)
P10	Perpendicular magnetic properties and magnetic damping constant of thin CoFeB films <u>M. Oogane</u> , M. Kubota, H. Naganuma, and Y. Ando (Tohoku University)
P11	Spin torque diode effect in magnetic tunnel junction using L1o-ordered free layer <u>H. Naganuma</u> , K. Hatakeyama, G. Kim, Y. Kawada, M. N. I. Khan, N. Inami, M. Oogane, Y. Ando (Tohoku University)
P12	Bias voltage dependence of spin torque diode effect in CoFeB/MgO/CoFeB magnetic tunnel junction <u>Tian Yu</u> , H. Naganuma, N. Inami, M. Oogane, Yasuo Ando (Tohoku University)

P13	Dependence of perpendicular magnetic anisotropy of $L1_0$-FePd/CoFeB films on post-deposition annealing temperature <u>M. N. I. Khan</u> , H. Naganuma, M. Oogane and Y. Ando (Tohoku University)
P14	Depinning error rate of domain wall in Co/Ni nanowire <u>S. Fukami</u> , M. Yamanouchi, S. Ikeda and H. Ohno (Tohoku University)
P15	A New Sensing Scheme with High Signal Margin Suitable for Spin-Transfer Torque RAM <u>H. Koike</u> , T. Ohsawa and T. Endoh (Tohoku University)
P16	600MHz Nonvolatile Latch Based on a New MTJ/CMOS Hybrid Circuit Concept T. Endoh ¹ , S. Togashi ¹ , F. Iga ¹ , Y. Yoshida ¹ , T. Ohsawa ¹ , <u>H. Koike</u> ¹ , S. Fukami ¹ , S. Ikeda ¹ , N. Kasai ¹ , N. Sakimura ^{1, 2} , T. Hanyu ¹ , and H. Ohno ¹ (¹ Tohoku University, ² NEC Corporation)
P17	A Fine-Grained Power Gating Architecture for MTJ-based Embedded Memories <u>T. Ohsawa</u> ¹ , H. Kioke ¹ , S. Miura ^{1, 2} , H. Honjo ^{1, 2} , K. Tokutome ^{1, 2} , S. Ikeda ¹ , T. Hanyu ¹ , H. Ohno ¹ , and T. Endoh ¹ (¹ Tohoku University, ² NEC Corporation)
P18	Two-Step Writing Method for STT-MTJ to Improve Switching Probability and Write Speed F. Iga, Y. Suzuki, <u>T. Ohsawa</u> , S. Ikeda, T. Hanyu, H. Ohno, and T. Endoh (Tohoku University)
P19	Magnetic tunnel junctions consisting of Co/Pt multilayer and a CoFeB insertion layer with high thermal stability <u>S. Ishikawa</u> , H. Sato, M. Yamanouchi, S. Ikeda, S. Fukami, F. Matsukura, and H. Ohno (Tohoku University)
P20	Electrical detection of ferromagnetic resonance in (Ga,Mn)As L. Chen, F. Matsukura and H. Ohno (Tohoku University)
P21	Measurement of magnetic properties in CoFeB-MgO p-MTJs by ferromagnetic resonance with homodyne detection technique <u>K. Mizunuma</u> , M. Yamanouchi, H. Sato, S. Ikeda, S. Kanai, F. Matsukura, and H. Ohno (Tohoku University)
P22	Magnetic Field Angle Dependence of the Probabilities of Electric-Field Induced Magnetization Switching <u>S. Kanai</u> ¹ , M. Yamanouchi ¹ , S. Ikeda ¹ , Y. Nakatani ² , F. Matsukura ¹ , and H. Ohno ¹ (¹ Tohoku University, ² University of Electro-communications)